

FOR IMMEDIATE RELEASE

Cambridge NanoTech is named a “Fastest Growing Company”
for second consecutive year
Recognized as Pacesetter by Boston Business Journal

CAMBRIDGE, MA, May 18, 2010 – [Cambridge NanoTech](#), the world leader in [Atomic Layer Deposition](#) (ALD), has been recognized for the second consecutive year as one of the “Fastest Growing Private Companies” by the Boston Business Journal (BBJ). With an aggressive 234% growth, Cambridge NanoTech ranked #5 out of the 51 companies that were recognized this year.

“We’re honored to be recognized by the BBJ,” said Jill Becker, Founder & CEO of Cambridge NanoTech. “We’ve managed our rapid growth over the past year with a team of highly talented people. Diversifying our product line and investing during a down economy have also been crucial to our progress. Our growth has allowed us to create new jobs and expand our staff by 50% by hiring nine new employees in the past eight weeks.”

About Cambridge NanoTech

Cambridge NanoTech delivers Atomic Layer Deposition (ALD) systems capable of depositing ultra-thin films that are used in a wide variety of research and industrial applications. Our manufacturing ALD systems are used in the production of semiconductors, flat panel displays, photovoltaics and solid state lighting. Cambridge NanoTech research systems are used by world class scientists on five continents to study superior ALD film properties such as electrical, anti-bacterial, UV blocking and anti-reflection.

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